

United States Patent and Trademark Office

UNITED STATES DEPARTMENT OF COMMERCE United States Patent and Trademark Office Address: COMMISSIONER FOR PATENTS P.O. Box 1450 'Alexandria, Virginia 22313-1450 www.uspto.gov

APPLICATION NO.	# FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
09/685,042	10/10/2000	Shuichi Kobayashi	35.G2657	3110
5514	7590 12/24/2003		EXAMINER	
FITZPATRICK CELLA HARPER & SCINTO 30 ROCKEFELLER PLAZA			CHANG, AUDREY Y	
NEW YORK,			ART UNIT	PAPER NUMBER
•			2872	
			DATE MAILED: 12/24/2003	3

Please find below and/or attached an Office communication concerning this application or proceeding.

		- li				
	Application No.	Applicant(s)				
Office Action Summany	09/685,042	KOBAYASHI, SHUICHI				
Office Action Summary	Examiner	Art Unit				
	Audrey Y. Chang	2872				
The MAILING DATE of this communicatio Period for Reply	n appears on the cover sneet v	vith the correspondence address				
A SHORTENED STATUTORY PERIOD FOR R THE MAILING DATE OF THIS COMMUNICATI - Extensions of time may be available under the provisions of 37 C after SIX (6) MONTHS from the mailing date of this communication. - If the period for reply specified above is less than thirty (30) days - If NO period for reply is specified above, the maximum statutory - Failure to reply within the set or extended period for reply will, by - Any reply received by the Office later than three months after the earned patent term adjustment. See 37 CFR 1.704(b). Status	ON. FR 1.136(a). In no event, however, may a on. a reply within the statutory minimum of the period will apply and will expire SIX (6) MC statute, cause the application to become A	reply be timely filed irty (30) days will be considered timely. INTHS from the mailing date of this communication. ABANDONED (35 U.S.C. § 133).				
1) Responsive to communication(s) filed on	23 September 2003.					
2a) ☐ This action is FINAL . 2b) ☑	This action is non-final.					
3) Since this application is in condition for al closed in accordance with the practice un	Since this application is in condition for allowance except for formal matters, prosecution as to the merits is closed in accordance with the practice under <i>Ex parte Quayle</i> , 1935 C.D. 11, 453 O.G. 213.					
Disposition of Claims						
4) Claim(s) 1,4,7,11,13,15,17 and 18 is/are pending in the application.						
4a) Of the above claim(s) is/are wit	4a) Of the above claim(s) is/are withdrawn from consideration.					
5) Claim(s) is/are allowed.	Claim(s) is/are allowed.					
6)⊠ Claim(s) <u>1,4,7,11,13,15,17 and 18</u> is/are rejected.						
	Claim(s) is/are objected to.					
8) Claim(s) are subject to restriction a	and/or election requirement.					
Application Papers						
9) The specification is objected to by the Examiner.						
10)☐ The drawing(s) filed on is/are: a)☐ accepted or b)☐ objected to by the Examiner.						
Applicant may not request that any objection to the drawing(s) be held in abeyance. See 37 CFR 1.85(a).						
Replacement drawing sheet(s) including the correction is required if the drawing(s) is objected to. See 37 CFR 1.121(d).						
11) The oath or declaration is objected to by the Examiner. Note the attached Office Action or form PTO-152.						
Priority under 35 U.S.C. §§ 119 and 120						
12) Acknowledgment is made of a claim for for a) All b) Some * c) None of: 1. Certified copies of the priority docu 2. Certified copies of the priority docu 3. Copies of the certified copies of the application from the International B * See the attached detailed Office action for 13) Acknowledgment is made of a claim for do since a specific reference was included in to 37 CFR 1.78. a) The translation of the foreign language 14) Acknowledgment is made of a claim for do reference was included in the first sentence.	ments have been received. ments have been received in e priority documents have been fureau (PCT Rule 17.2(a)). a list of the certified copies not mestic priority under 35 U.S.C he first sentence of the specified ge provisional application has mestic priority under 35 U.S.C	Application No In received in this National Stage of received. C. § 119(e) (to a provisional application) ication or in an Application Data Sheet. been received. C. §§ 120 and/or 121 since a specific				
Attachment(s)						
 Notice of References Cited (PTO-892) Notice of Draftsperson's Patent Drawing Review (PTO-943) Information Disclosure Statement(s) (PTO-1449) Paper No. 	18) 5) Notice o	v Summary (PTO-413) Paper No(s) f Informal Patent Application (PTO-152)				

Applicâtion/Control Number: 09/685,042 Page 2

Art Unit: 2872

DETAILED ACTION

Continued Examination Under 37 CFR 1.114

- 1. A request for continued examination under 37 CFR 1.114, including the fee set forth in 37 CFR 1.17(e), was filed in this application after final rejection. Since this application is eligible for continued examination under 37 CFR 1.114, and the fee set forth in 37 CFR 1.17(e) has been timely paid, the finality of the previous Office action has been withdrawn pursuant to 37 CFR 1.114. Applicant's submission filed on September 23, 2003 has been entered.
- 2. This Office Action is also in response to applicant's amendment filed on September 23, which has been entered as paper number 20.
- 3. By this amendment, the applicant has amended claims 1, 7, 11.
- 4. Claims 1, 4, 7, 11, 13, 15, 17 and 18 remain pending in this application.

Response to Amendment

5. The amendment filed on September 23, 2003 is objected to under 35 U.S.C. 132 because it introduces new matter into the disclosure. 35 U.S.C. 132 states that no amendment shall introduce new matter into the disclosure of the invention. The added material which is not supported by the original disclosure is as follows: Claims 1 and 11 have been amended to include the feature "the first diffraction part reduces the incident angle of a light ray which is incident on said second diffraction part". The first diffractive part, which has *positive power*, that would converge the light toward the second diffractive part which will not be able to "reduce" the angle of incident.

Claim Rejections - 35 USC § 112

6. The following is a quotation of the first paragraph of 35 U.S.C. 112:

The specification shall contain a written description of the invention, and of the manner and process of making and using it, in such full, clear, concise, and exact terms as to enable any person skilled in the art to which it

Art Unit: 2872

pertains, or with which it is most nearly connected, to make and use the same and shall set forth the best mode contemplated by the inventor of carrying out his invention.

Claims 1, 4, 7, 11, 13, 17 and 18 are rejected under 35 U.S.C. 112, first paragraph, as containing subject matter which was not described in the specification in such a way as to reasonably convey to one skilled in the relevant art that the inventor(s), at the time the application was filed, had possession of the claimed invention. The reasons for rejection are based on the newly added matters set forth in the paragraph above. The applicant is respectfully noted that if the first diffractive part has a positive power, the light will be converged more, which therefore will not be able to reduce the incident angle. For if the first diffractive part has a negative power, the light will be diverged, which depends on the incident angle of the light to the first diffractive optical part, the angle may either be increased or reduced by the diffractive action. Claims 4, 7, 13, 17 and 18 inherit the rejections.

Claim Rejections - 35 USC § 103

The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

- (a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.
- 8. Claims 1, 4, 7 and newly added claim 17 are rejected under 35 U.S.C. 103(a) as being unpatentable over the patent issued to Mukai et al (PN. 6,052,234) in view of the patent issued to Ishii (PN. 6,157,488).

Mukai et al teaches a viewfinder optical system having an objective optical system (tg, Figure 7) in front of a pupil (he), wherein the objective lens system comprises a double concave lens (g1), which is a negative lens, having a diffractive surface (s2) and a convex lens (g2), which is a positive lens, having a

Art Unit: 2872

negative lens is having negative power and the diffractive surface on the positive lens is having negative power and the diffractive surface on the positive lens is having a positive power, (please see column 6, lines 33-36), such that the first diffractive surface has a negative power and the second diffractive surface has a positive power. It is implicitly true that the second diffractive surface is behind the first diffractive surface since the incident light reaches the first diffractive surface first. The first diffractive surface will diverge the incident light toward the second diffractive surface as shown in Figure 7, the light incidents on the first lens at a non-zero incident angle will have its angle with respect to normal reduced by the first diffractive surface. With regard to the features concerning the "layered diffraction optical member laminated with a plurality of diffraction parts", in light of the specification and the drawings 1B, 4B and 6B, it is understood that the phrase means that two diffraction parts are formed at different optical elements with the combination of the two elements serves as the "layered diffraction optical member". With this interpretation, the objective lens system having the negative lens with the negative power diffraction surface is considered to be the "layered diffraction optical member", wherein the diffraction surfaces are laminated on the lens elements.

This reference has met all the limitations of the claims with the exception that Mukai et al does not teach explicitly that the two diffractive optical elements are made with materials of different wavelength dispersion property. Ogata does teach about to design the lens system with correction of the chromatic aberration. Ishii in the same field of endeavor teaches a diffractive optical element having layered diffractive surfaces or parts that also has refractive power (please see Figures 22 and 23), wherein the diffractive surfaces are formed on optical materials of different dispersion properties, (please se column 13, lines 33-54) in order to achieve achromatic condition, (i.e. reduce or eliminating the chromatic aberrations in the lens system). It would then have been obvious to one skilled in the art to apply the teachings of Ishii to modify the optical system of Mukai et al for the benefit of providing a

Art Unit: 2872

design for the diffractive surfaces to more effectively achieve the achromatic condition and to reduce the aberrations given rise by the diffractive surfaces.

The lens system is designed to be a viewfinder that implicitly implied to be operated in the visible wavelength range. With regard to claim 4, Mukai et al teaches that an air space separation is between the two diffractive optical elements, (pleas see Figure 7). With regard to claim 7, Mukai et al teaches that the optical system further comprises other lens groups, which serve as the refractive optical devices.

With regard to claim 17, Mukai et al does not teach explicitly that the diffractive surfaces are of blaze shapes. However diffractive lens having blaze shape is very well known in the art as demonstrated by the teachings of Ishii (Figure 6). Ishii also teaches that the orientation of the blaze shape may be opposite to each other, (please see Figure 31). It would then have been obvious to one skilled in the art to modify the diffractive surfaces of Mukai et al in accordance with the teachings of Ishii for the benefit of providing the diffractive surfaces with high diffraction efficiency.

9. Claims 11, 13, 15 and newly added claim 18 are rejected under 35 U.S.C. 103(a) as being unpatentable over the patent issued to Ushida et al in view of the patent issued to Ishii (PN. 6,157,488).

Ushida et al teaches a projection optical system that is comprised of a layered diffraction optical system laminated with diffraction optical elements (G₁ and G₂) wherein the layered diffraction optical system is placed behind an aperture stop element (element 25 in Table 2) or iris, that serves as the pupil, of the projection optical system. Ushida et al teaches that the first diffraction optical element has a positive power and the second diffractive optical element has negative power, (please see column 6, Figures 1-2). Ushida et al teaches that the first diffractive optical element is made of glass material such as quartz and the second diffractive optical element is made of glass material such as fluorite wherein quartz and fluorite have different wavelength dispersion property, (please see column 6, lines 24-29). It is

Art Unit: 2872

implicitly true that the diffractive optical elements have high diffraction efficiency in the intended wavelength range. It is implicitly true that the first diffractive optical element converges the incident light toward the second diffractive optical element.

With regard to the features that the projection lens has high diffraction efficiency for diffracting light in the *visible* wavelength range, this reference does *not* teach explicitly about the wavelength range intended for operation. However projection system such as *image projection system* or even exposure projection system using visible light is very well known in the art such feature is therefore either inherently met by the disclosure or an obvious modification to one skilled in the art for the benefit of allowing the projection system to be operable in the visible wavelength range. Furthermore, **Ishii** in the same field of endeavor teaches a diffractive optical element with layered diffractive elements wherein the diffractive element is being designed to have high diffraction efficiency in the visible wavelength range, (please see Figure 11). It would then have been obvious to one skilled in the art to apply the teachings of Ishii to modify the diffractive elements of Ushida, if this is not already the case, to make it have high diffraction efficiency in the visible range.

With regard to claim 13, this reference however does not teach explicitly that the diffractive optical elements are laminated with an air layer interposed. But such modification is either implicitly included since the diffraction optical elements have stair case profile as shown in Figures 2 and 3 which makes them necessary to have air space between the two elements or an obvious modification to one skilled in the art to achieve desired diffraction/refraction property, by interposing an refractive air medium. With regard to claim 15, the projection optical system comprises other lenses that serve as refractive optical device, (pleas see Figure 2).

With respect to newly added claim 18, Ushida et al teaches that the diffraction optical elements has stair case configuration that are of blaze shapes, (please see Figures 3 and 4). This reference however does not teach explicitly that the orientations of the diffractive optical elements are opposite to each other.

Art Unit: 2872

Ishii in the same field of endeavor teaches that the orientation of the blaze shape may be opposite to each other, (please see Figure 31). It would then have been obvious to one skilled in the art to modify the diffractive surfaces of Mukai et al in accordance with the teachings of Ishii for the benefit of providing the diffractive surfaces with high diffraction efficiency.

Response to Arguments

- 10. Applicant's arguments with respect to claims 1, 4, 7, and 17 have been considered but are moot in view of the new ground(s) of rejection.
- In response to applicant's arguments, which state that, the cited Ushida et al reference discloses a 11. photolithographic projection system and make reference to "deep ultra violet region" but not visible wavelength range, the examiner respectfully disagrees for the reasons stated below. Firstly the examiner wishes to point out respectfully that Ushida et al reference discloses a projection optical system wherein NO SPECIFIC range of wavelength for operation is ever given. Applicant is respectfully reminded that although the Japanese patent 4-214516 is mentioned in the cited Ushida reference, no reference of any kind to US patent 5,170,207 is given. Even if the US patent is considered a reference to the cited Ushida reference, the lens systems in the both references cannot be identical since the US patent (5,170,207) only has one Fresnel lens while the Ushida reference teaches two diffractive optical elements. Also none of the references teaches specifically of "preventing" the projection lens being used in visible wavelength ranges. It is known in the art that visible light wavelength is considered to be higher harmonics of ultraviolet wavelength. In theory, there cannot be prevention of the projection lens from used in either of the wavelength regions only. Furthermore, the reference to deep ultra violet region is only mentioned as a general property of a binary optics (BOE), (please see column 4, lines 7-14), but no where in the reference ever mentioned that the optical projection system is operable in the deep ultra violet wavelength region and such limitation cannot be applied here. A binary optics as well known in the art can be

Page 7

Art Unit: 2872

designed to diffract light in visible wavelength range, (please see the patent issued to Neal et al (PN.

5,864,381)). It is the fundamental theory of diffraction that diffraction property is determined by the

phase modulation of the diffractive optical element upon the incident light wherein the phase modulation

depends on the wavelength of the incident light. It is therefore an obvious modification to one skilled in

the art to design the diffractive optical element that is capable of diffracting light in the visible

wavelength region.

Furthermore, optical projection system is widely applied in the art as for image projection system

or lithographic system, wherein each of the systems can be operated by light in the visible wavelength

range. The applicant is respectfully reminded that the dependence of diffraction efficiency of the angle of

incident is true for light of any wavelength is not only for DUV light.

Any inquiry concerning this communication or earlier communications from the examiner should

be directed to Audrey Y. Chang whose telephone number is 703-305-6208. The examiner can normally

be reached on Monday-Friday (8:00-4:30), alternative Mondays off.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Drew

Dunn can be reached on 703-305-0024. The fax phone number for the organization where this

application or proceeding is assigned is 703-872-9306.

Any inquiry of a general nature or relating to the status of this application or proceeding should

be directed to the receptionist whose telephone number is 703-308-0956.

Audrey Y. Chang Primary Examine

Art Unit 2872

A. Chang, Ph.D.

Page 8